L Number	Hits	Search Text	DB	Time stamp
-	1815	(phase adj shift$3 same (mask or photomask or reticle)) same (resist or photoresist or photosensit$4)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/04/30 14:30
-	798	((phase adj shift$3 same (mask or photomask or reticle)) same (resist or photoresist or photosensit$4)) and (trim or ((mask or photomask or reticle) near3 set) or (second or complementary) adj (mask or photomask or reticle) or overla$5)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/04/28 16:37
-	126	(((phase adj shift$3 same (mask or photomask or reticle)) same (resist or photoresist or photosensit$4)) and (trim or ((mask or photomask or reticle) near3 set) or (second or complementary) adj (mask or photomask or reticle) or overla$5)) and (transistor near3 gate or gate adj shr?nk$3)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/04/28 16:25
-	97	((((phase adj shift$3 same (mask or photomask or reticle)) same (resist or photoresist or photosensit$4)) and (trim or ((mask or photomask or reticle) near3 set) or (second or complementary) adj (mask or photomask or reticle) or overla$5)) and (transistor near3 gate or gate adj shr?nk$3)) and (resolution or resolv$3)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB .	2003/04/28 16:25
-	89	(((((phase adj shift$3 same (mask or photomask or reticle)) same (resist or photoresist or photosensit$4)) and (trim or ((mask or photomask or reticle) near3 set) or (second or complementary) adj (mask or photomask or reticle) or overla$5)) and (transistor near3 gate or gate adj shr?nk$3)) and (resolution or resolv$3)) and (optical adj (parameter or configurat$3) or aperture or (wavelength or coherenc$1 or illumina$4 or focus or defocus) same (expos$3 or radia$4 or irradia$4 or light or illumina$4))	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/04/28 16:26
-	65	((((((phase adj shift$3 same (mask or photomask or reticle)) same (resist or photoresist or photosensit$4)) and (trim or ((mask or photomask or reticle) near3 set) or (second or complementary) adj (mask or photomask or reticle) or overla$5)) and (transistor near3 gate or gate adj shr?nk$3)) and (resolution or resolv$3)) and (optical adj (parameter or configurat$3) or aperture or (wavelength or coherenc$1 or illumina$4 or focus or defocus) same (expos$3 or radia$4 or irradia$4 or light or illumina$4))) and (dose or dosage or intensity)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/04/28 16:28

–	24	`((((((phase adj shift$3 same (mask or photomask or reticle)) same (resist or photoresist or photosensit$4)) and (trim or ((mask or photomask or reticle) near3 set) or (second or complementary) adj (mask or photomask or reticle) or overla$5)) and (transistor near3 gate or gate adj shr?nk$3)) and (resolution or resolv$3)) and (optical adj (parameter or configurat$3) or aperture or (wavelength or coherenc$1 or illumina$4 or focus or defocus) same (expos$3 or radia$4 or irradia$4 or light or illumina$4))) not ((((((phase adj shift$3 same (mask or photomask or reticle)) same (resist or photoresist or photosensit$4)) and (trim or ((mask or photomask or reticle) near3 set) or (second or complementary) adj (mask or photomask or reticle) or overla$5)) and (transistor near3 gate or gate adj shr?nk$3)) and (resolution or resolv$3)) and (optical adj (parameter or configurat$3) or aperture or (wavelength or coherenc$1 or illumina$4 or focus or defocus) same (expos$3 or radia$4 or irradia$4 or light or illumina$4))) and (dose or dosage or intensity))`	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/04/28 16:28
–	2	`(("20020187636") or ("20020197543")).PN.`	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/04/28 16:33
–	22	`(("6284419") or ("6519501") or ("20020076622") or ("6453457") or ("6337172") or ("6541165") or ("6503666") or ("6162568") or ("6255024") or ("6268091") or ("6319644") or ("6421111") or ("5972569") or ("5405721") or ("6042973") or ("6127096") or ("6374396") or ("6096457") or ("6106979") or ("6040892") or ("6120952") or ("5741624")).PN.`	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/04/28 16:34
–	21	`(((("20020187636") or ("20020197543")).PN.) or ((("6284419") or ("6519501") or ("20020076622") or ("6453457") or ("6337172") or ("6541165") or ("6503666") or ("6162568") or ("6255024") or ("6268091") or ("6319644") or ("6421111") or ("5972569") or ("5405721") or ("6042973") or ("6127096") or ("6374396") or ("6096457") or ("6106979") or ("6040892") or ("6120952") or ("5741624")).PN.)) not ((((((phase adj shift$3 same (mask or photomask or reticle)) same (resist or photoresist or photosensit$4)) and (trim or ((mask or photomask or reticle) near3 set) or (second or complementary) adj (mask or photomask or reticle) or overla$5)) and (transistor near3 gate or gate adj shr?nk$3)) and (resolution or resolv$3)) and (optical adj (parameter or configurat$3) or aperture or (wavelength or coherenc$1 or illumina$4 or focus or defocus) same (expos$3 or radia$4 or irradia$4 or light or illumina$4)))`	USPAT; US-PGPUB	2003/04/28 16:35

–	398	((430/5,311–312,319,394,396 or 355/53,77 or 378/34–35 or 716/19–21).ccls. and (phase adj shift$3 same (mask or photomask or reticle)) same (trim or ((mask or photomask or reticle) near3 set) or (second or complementary) adj (mask or photomask or reticle) or overla$5)) not (((((phase adj shift$3 same (mask or photomask or reticle)) same (resist or photoresist or photosensit$4)) and (trim or ((mask or photomask or reticle) near3 set) or (second or complementary) adj (mask or photomask or reticle) or overla$5)) and (transistor near3 gate or gate adj shr?nk$3)) and (resolution or resolv$3)) and (optical adj (parameter or configurat$3) or aperture or (wavelength or coherenc$1 or illumina$4 or focus or defocus) same (expos$3 or radia$4 or irradia$4 or light or illumina$4)))	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/05/13 18:22
–	4	(("5885734") or ("6077630") or ("20010000240") or ("20010028985")).PN.	USPAT; US-PGPUB	2003/04/28 18:09
–	48	(("4037918") or ("4456371") or ("5302477") or ("5308741") or ("5316878") or ("5324600") or ("5328807") or ("5334542") or ("5352550") or ("5364716") or ("5424154") or ("5480746") or ("5496666") or ("5498579") or ("5503951") or ("5523186") or ("5527645") or ("5532090") or ("5537648") or ("5538815") or ("5539568") or ("5565286") or ("5573890") or ("5595843") or ("5620816") or ("5635316") or ("5636131") or ("5702848") or ("5725969") or ("5761075") or ("5766804") or ("5766806") or ("5807649") or ("5827623") or ("5858580") or ("5885734") or ("5923566") or ("5994002") or ("5998068") or ("6004702") or ("6010807") or ("6057063") or ("6066180") or ("6077630") or ("6083275") or ("6228539") or ("6251549") or ("6258493")).PN.	USPAT; US-PGPUB	2003/04/30 14:58
–	9	(("5472814") or ("5923562") or ("6130012") or ("6139994") or ("6185727") or ("6335128") or ("6338922") or ("20010000240") or ("20010028985")).PN.	USPAT; US-PGPUB	2003/04/30 15:02
–	12	(("6420074") or ("6436590") or ("20020083410") or ("20020122994") or ("20020127479") or ("20020129327") or ("20020136964") or ("20020142231") or ("20020142232") or ("20020144232") or ("20020152454") or ("20020155363")).PN.	USPAT; US-PGPUB	2003/04/30 15:06
–	6	((full or complete or overall) adj phase adj shift$3 adj (mask or reticle or photomask) same (resist or photoresist)) and 430/5.ccls.	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/05/08 17:54
–	1	("6524752").PN.	USPAT; US-PGPUB	2003/05/08 16:46
–	4	((full adj phase adj shift$3 or full adj phase) adj (mask or reticle or photomask)) not (((full or complete or overall) adj phase adj shift$3 adj (mask or reticle or photomask) same (resist or photoresist)) and 430/5.ccls.)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/05/08 16:56

–	357	((dose or dosing or dosage or intensity) same (second adj (mask or photomask or reticle))) not (((430/5,311-312,319,394,396 or 355/53,77 or 378/34-35 or 716/19-21).ccls. and (phase adj shift$3 same (mask or photomask or reticle)) same (trim or ((mask or photomask or reticle) near3 set) or (second or complementary) adj (mask or photomask or reticle) or overla$5)) not ((((((phase adj shift$3 same (mask or photomask or reticle)) same (resist or photoresist or photosensit$4)) and (trim or ((mask or photomask or reticle) near3 set) or (second or complementary) adj (mask or photomask or reticle) or overla$5)) and (transistor near3 gate or gate adj shr?nk$3)) and (resolution or resolv$3)) and (optical adj (parameter or configurat$3) or aperture or (wavelength or coherenc$1 or illumina$4 or focus or defocus) same (expos$3 or radia$4 or irradia$4 or light or illumina$4))))	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/05/13 18:49
–	16	(((dose or dosing or dosage or intensity) same (second adj (mask or photomask or reticle))) not (((430/5,311-312,319,394,396 or 355/53,77 or 378/34-35 or 716/19-21).ccls. and (phase adj shift$3 same (mask or photomask or reticle)) same (trim or ((mask or photomask or reticle) near3 set) or (second or complementary) adj (mask or photomask or reticle) or overla$5)) not ((((((phase adj shift$3 same (mask or photomask or reticle)) same (resist or photoresist or photosensit$4)) and (trim or ((mask or photomask or reticle) near3 set) or (second or complementary) adj (mask or photomask or reticle) or overla$5)) and (transistor near3 gate or gate adj shr?nk$3)) and (resolution or resolv$3)) and (optical adj (parameter or configurat$3) or aperture or (wavelength or coherenc$1 or illumina$4 or focus or defocus) same (expos$3 or radia$4 or irradia$4 or light or illumina$4))))) and (resist or photoresist) and phase adj shift$3 same (mask or photomask or reticle)	USPAT; US-PGPUB; EPO; JPO; IBM_TDB	2003/05/13 18:51